

Forthcoming conferences

Readers are invited to send the Executive Editor details of conferences to be announced

Photonics West

The 1999 Photonics West Conference and Exhibition will be held January 23-29, 1999 in San Jose, CA. The technical meeting will international symposia on high-power laser and applications, integrated optoelectronic devices and applications, and electronic imaging: science and technology.

Contact: SPIE
PO Box 10
Bellingham, WA 98227 USA
Tel. (1) 360 676 3290
Fax. (1) 360 647 1445
Net or Web: spie@spie.org or <http://www.spie.org>

1999 International Solid-State Circuits Conference

ISSCC'99 will be held February 15-17, 1999 in San Francisco, CA. The theme for this year is high-bandwidth systems.

Contact: ISSCC '99
Diane Suiters
Courtesy Associates
2000 L. Street N.W. Suite # 710
Washington, DC 20036 USA
Tel. (1) 202 973 8667
Fax. (1) 202 331 0111
Net: isscc@courtesyassoc.com

1999 IEEE MTT-S

International Topical Symposium on Technologies for Wireless Applications
This conference will be held February 21-24, 1999 in Vancouver B.C., Canada. It is intended to highlight the application of RF, microwave and mm-wave technologies to all aspects of wireless communications.

Contact: Mr Bernard D. Geller
c/o LRW associates
468 Walden Trail
Waxhaw, NC 28172
Tel. (704) 841 1915
Fax. (704) 845 3078

OFC 1999

The 1999 International Conference on Integrated Optics and Optical Fiber Communication will be held Feb. 21-26, 1999 in San Diego, CA.

Contact: Mr Lisa Myers
OSA Conference Services
2010 Massachusetts Ave., NW
Washington, DC 20036-1023
Tel. (1) 202 416 1980
Fax. (1) 202 416 6100
Net or Web: ofic.info@osa.org or <http://www.osa.org>

Compound Semiconductor Outlook '99

Compound Semiconductor Outlook'99 will be held March 1-3, 1999 in Santa Clara, CA. This conference, organised by Gorham/Intertech Consulting, will cover trends and forecasts for the compound semiconductor industry, as well as addressing manufacturing and applications-related issues.

Contact: Chris Jones
Gorham/Intertech Consulting
PO Box 205
211 Mosher Road
Gorham, ME 04038 USA
Tel. (1) 207 892 5445
Fax. (1) 207 892 2210
Net or Web: www.goradv.com
or www.intertechusa.com

11th International Conference on the Microscopy of Semiconducting Materials

The 11th Int'l Conf. on the Microscopy of Semiconducting Materials will be held March 22-25, 1999 at the University of Oxford, UK. The conference will focus on the latest developments in the study of the structural and electronic properties of semiconducting materials by the application of transmission and scanning electron microscopy. Other characterisation techniques such as X-ray imaging and diffraction, scanning probe microscopy and atom probe microanalysis will also be featured. The materials of interest cover the complete range of elemental and compound semiconductors, as well as the dielectric materials and metallisation used in integrated devices.

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Northants NN12 8EQ UK
Tel. (44) 1327 356363
Fax. (44) 1327 356389
Net or Web: richard.beanland@gecm
or <http://www.iop.org>

10th European Workshop on MBE

Euro MBE '99 will be held March 28- April 1, 1999 at Les Arcs (Savoie), France. The aim of this workshop is to bring together research and engineers involved in the development and/or application of MBE and related techniques to address the latest scientific and technological issues in an informal atmosphere.

Abstract Deadline: January 1, 1999

Contact: Eric Tournie
CRHEA/CNRS
Rue Bernard Gregory
Sophia Antipolis
F-06560 Valbonne France
Tel. (33) 4 9395 4224
Fax. (33) 4 9395 8361
Net or Web: et@crhea.cnrs.fr

1999 Spring MRS Meeting

MRS is being held April 5-9, 1999 in San Francisco, California. Symposia for this year's meeting include: physics and technology of dopant-defect interactions; advanced semiconductor wafer engineering; in-situ process diagnostic and modelling; epitaxial growth principles and applications; semiconductor quantum dots; wide-bandgap semiconductors for high-power, high-frequency, and high-temperature applications; and compound semiconductor surface passivation and novel device processing.

Abstract Deadline: October 19, 1998

Contact: MRS
506 Keystone Drive
Warrendale, PA 15086 7573
Tel. (1) 724 779 3003
Fax. (1) 724 779 8313
Net or Web: info@mrs.org or <http://www.mrs.org>

Quantum Optoelectronics 1999

QOE will be held April 12-16, 1999 in Aspen, Colorado. Topics to be considered include: photon confinement phenomena; microcavity devices; quantum devices; novel spectroscopies of quantum systems; ultrafast phenomena; coherent control and spectroscopy; quantum dots, wires, and wells; novel materials for quantum optoelectronics; short-wavelength semiconductor lasers and LEDs; long-wavelength semiconductor light sources and detectors.

Abstract Deadline: December 10, 1998

Contact: OSA Conference Services
2010 Massachusetts Ave.
NW Washington, DC 20036-1023
Tel. (1) 202 416 1980
Fax. (1) 202 416 6100
Net or Web: infor@osa.org or <http://www.osa.org>

Ultrafast Electronics and Optoelectronics

UEO will be held April 12-16, 1999 in Aspen, Colorado. Topics to be considered include: new sources of high speed or high-frequency optical and electrical signals and pulses; advances in high-speed and high-frequency devices, circuits, and systems; novel structures and devices; optoelectronics devices and logic, high-speed modulators and photodetectors; all-optical techniques; and applications.

Abstracts Deadline: December 10, 1998

Contact: OSA Conference Services
2010 Massachusetts Ave.
NW Washington, DC 20036-1023
Tel. (1) 202 416 1980
Fax. (1) 202 416 6100
Net or Web: infor@osa.org or <http://www.osa.org>

1999 International Conference on Gallium Arsenide Manufacturing Technology

The GaAs Conference will be held April 19-22, 1999 in Vancouver, British Columbia, Canada. Papers that address solutions to real and potential manufacturing problems are sought in areas including: manufacturing; processing; test & reliability; device technologies; materials; packaging; optical devices; and future business outlook. There will also be an "Ugly Picture Contest" – designed as an opportunity to present examples of process problems and solutions without submitting a full paper.

Abstracts Deadline: October 30, 1998

Contact: Ding Day
NDI
1230 Bordeaux Drive
Sunnyvale CA 94089
Tel. (1) 408 734 9888 xt. 118
Fax. (1) 408 743 9889
Net or Web: dday@network-device.com
or <http://www.GaAsManTech.org>

15th Meeting of the Electrochemical Society

The ECS meeting will be held May 2-7, 1999 in Seattle, Washington. Several semiconductor-related symposia will be held, including SOTAPOCS XXX: State-of-the Art Program on Compound Semiconductors.

Abstracts Deadline: January 2, 1999

Contact: ECS
10 South Main Street
Pennington, NJ 08534-2896, USA
Tel. (1) 609 737 1902
Fax. (1) 609 737 2743
Net or Web: ecs@electrochem.org
or <http://electrochem.org/meetings/195/symp.html>